Refractive Index Sensor Based on Metal-Clad Planar Polymer Waveguide Operating at 850 nm

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Abstract: A metal-clad planar polymer waveguide refractive index sensor based on epoxy (EPO) polymer materials by using light intensity interrogation at 850 nm is designed. The polymethyl methacrylate (PMMA) material is deployed as the low refractive index (RI) buffer layer in order to better couple the optical guided mode and the surface plasmon polaritons (SPP) mode for working in water environment. The effects of the gold film thickness, PMMA buffer layer thickness, waveguide layer thickness, waveguide width, and gold length on the sensor sensing characteristics have been comprehensively studied. Simulation results demonstrate that the normalized transmission increases quasi-linearly with the increment of RI of the analyte from 1.33 to 1.46. The sensitivity is 491.5 dB/RIU, corresponding to a high RI resolution of 2.6×10^{-9} RIU. The designed SPP-based optical waveguide sensor is low-cost, wide-range, and high-precision, and has a broad application prospect in biochemical sensing with merits of miniaturization, flexibility, and multiplexing.

Keywords: Metal-clad optical waveguide sensor; intensity interrogation; refractive index of liquid

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1. Introduction

Refractive index (RI) is a critical parameter of liquid closely related to density, concentration, and temperature. The monitoring of RI of liquid is very important in fields of chemistry, medicine, physics, biology, and production practices. Surface plasmon polariton (SPP) is a kind of electromagnetic waves propagating along the metal-dielectric interface and has a sensitive response to the variation of RI of dielectric adjacent to the metal film [1, 2]. The surface plasmon resonance (SPR) technology has now penetrated into the fields of food, biology, and environment, and demonstrated many advantages, such as high sensitivity, real-time detection, label-free, and selective recognition [3–7]. Due to

the wavevector mismatch with optical waves, SPP waves are traditionally excited by using the Kretschmann or Otto prism based on attenuated total reflection, which has disadvantages of large volume, complex system, and high cost [8–10]. Then, the integrated optical waveguide technology is exploited to fabricate SPR sensor chips with advantages of low cost, small size, and easy integration [11–13]. The planar optical waveguide structure is used as the coupling channel, which avoids the complex prism system and is easy to interact with the external system. The waveguide-type SPR sensor can integrate the sensing area of the SPR with other semiconductor photoelectric devices to form a micro-on-chip detection system, which combines the manufacturing advantage of the silicon technology

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and the information transfer advantage of the optical waveguide. By optimizing the design, a better coupling between the optical guided mode and SPP mode can be achieved. In order to improve the performance of SPR sensors, many kinds of structures have been proposed, including polymer long-period waveguide grating with the liquid cladding [5], molecular imprinted based SPR sensor [7], and fiber-optic waveguide coupled SPR sensor [14]. Fan *et al.* [15] realized ultra-thin layer sensing by using a vertical SPP-dielectric waveguide coupler, and the detection sensitivity was as high as 0.67 dB/nm. Ma *et al.* [16] reported a biosensor based on the coupling between the long-range SPP waveguide and dielectric waveguide. The sensitivity was 4180 nm/RIU, and the detection limit was up to 3.7×10^{-7} RIU. However, most of these works are done with wavelength interrogation and heavily rely on precise spectrometers and broadband optical sources, which are expensive, large-volume, and complex. This is difficult for low-cost, small-size, and portable monolithic integration. Compared with spectral interrogation, intensity interrogation becomes more and more portable and practical. Especially, with advances in laser diodes, photodetectors, and packaging technologies, SPR sensors based on intensity interrogation have demonstrated benefits of high resolution, high stability, easy integration, and multiplexing.

In this work, we present a waveguide-type SPR sensor based on epoxy (EPO) polymer materials by using light intensity interrogation at 850 nm. The cost of light sources and detectors or cameras is low and aqueous solutions have a relatively low optical absorption at 850 nm. The polymethyl methacrylate (PMMA) material is deployed as the low RI buffer layer to better couple the guided mode and the SPP mode in aqueous environment. The effects of the gold film thickness, PMMA buffer layer thickness, waveguide thickness, waveguide width, and gold length on the performance of the sensor have been comprehensively studied. Simulations demonstrate

that the transmission increases quasi-linearly with the increment of liquid RI from 1.33 to 1.46. The sensitivity of the sensor with an Au sensing length of 0.7 mm is 491.5 dB/RIU. The RI resolution is as high as 2.6×10^{-9} RIU in the analyte RI range from 1.33 to 1.46, higher than those of the most SPR-based works that are on the 10^{-6} orders of magnitude [10–16].

2. Structure and principle

The metal-clad planar waveguide sensor is illustrated in Fig. 1. The waveguide consists of a rectangular core buried in a dielectric cladding on a silicon substrate. The width and height of the core are represented by w and h , respectively. The gold (Au) film with a thickness of t_{Au} and a length of L is deposited on the surface of the cladding. The Au film and the core are separated by a PMMA buffer layer with a thickness of t_b . The PMMA is a high molecular compound polymerized by methyl methacrylate with merits of low cost, smooth surface, and high mechanical strength, and shows an excellent optical property of high transparency in a wide optical band. The RI of the PMMA is about 1.495, and that of waveguide core is about 1.577. The use of the PMMA buffer layer allows for a better coupling between the guided mode and SPP mode in aqueous environment (IR range 1.33 – 1.46). The commercial polymer EpoCore and EpoClad features of low cost, high stability, and easy integration are chosen as the waveguide materials [11]. The refractive indices of EpoCore, EpoClad, PMMA, Au, and the analyte are denoted by n_{co} , n_{cl} , n_b , n_{Au} , and n_a , respectively. The analyte to be measured is liquid. When the guided mode propagates in the core, there exists the evanescent field in the cladding, and the SPPs mode is excited at the metal-analyte interface when satisfying the phase-matching condition. Due to the strong loss of SPPs, the coupling leads to a large waveguide mode loss. Even small variations in the RI of the analyte adjacent to the metal layer may result in large

changes in the coupling strength and then the attenuation of the waveguide mode.

Fig. 1 Schematic diagram of (a) the 3-dimensional (3D) structure and (b) cross section of the designed RI sensor.

3. Simulations

For the metal-clad planar waveguide, there exists an optical guided mode in the core layer and a surface plasma mode at the interface between the metal and adjacent dielectric as well. The interaction between the guided mode and SPP mode can be analyzed by studying the optical properties of individual modes propagating in the sensing region [11, 15, 17–19]. When the guided mode is phase matched to the SPP mode, the electromagnetic fields of the mode are concentrated on the metal film of the structure, so it has a strong optical absorption. The RI sensor is theoretically designed by using the mode expansion and propagation method based on the finite element method [12]. The analysis of this

configuration is based on the optical losses caused by the imaginary part of the complex propagation coefficient, which is related to the imaginary part of the effective indice of the guided mode. The modal absorption is derived from the complex propagation coefficient for the transverse magnetic (TM) modes of the structure, as a function of RI of the analyte. Firstly, the mode analysis is performed on the cross section of the optical metal-clad planar waveguide to calculate the roots of the eigenvalue equation. Then, according to the calculation results, the dispersion characteristics of the TM fundamental guided mode and SPP mode are extracted. The refractive indices are assumed as follows: $n_{co} = 1.577$, $n_{cl} = 1.565$, and $n_b = 1.495$. The variation of complex permittivity of Au with the wavelength is taken from the published experimental data [20]. Compared with the strong variation of complex permittivity of the gold film with the wavelength, material dispersion effects on the other media are negligible here. Because only the TM polarization waveguide mode can be coupled to the SPP mode, in the following simulations, we consider only TM modes.

Firstly, we calculate the dispersion properties of the individual guided mode and SPP mode based on the finite element method. The real and imaginary parts of effective RI of the waveguide are denoted by $\text{Re}(N_{\text{eff}})$ and $\text{Im}(N_{\text{eff}})$, respectively. Figure 2 shows the variation of $\text{Re}(N_{\text{eff}})$ with the wavelength. The structural parameters used here are as follows: $w = h = 3 \mu\text{m}$, $t_{\text{Au}} = 50 \text{ nm}$, $t_b = 500 \text{ nm}$, and $n_a = 1$. It is clear that the real parts of effective RI of the guided mode and SPP mode cross each other at 855 nm, so the propagation constants of the guided mode and SPP mode match well at the intersection point of $\lambda = 855 \text{ nm}$. In the implementation of the experiment, the fundamental TM mode could be excited in the input waveguide by the end-fire coupling method. To reduce the coupling loss, the tapered cylindrical optical fiber can be used. The fiber-waveguide energy coupling efficiency mainly depends upon the overlap between the core mode

and fiber mode. The power emerging from the sensing waveguide P_{out} is expressed as [21]

$$P_{\text{out}} = P_{\text{in}} C^2 e^{-2\alpha L_{\text{Au}}} \quad (1)$$

where P_{in} is the input power from the fiber, C is the end-fire coupling factor, $\alpha = 2\pi \text{Im}(N_{\text{eff}})/\lambda$ is the waveguide attenuation coefficient, and L_{Au} is the length of the gold area. The insertion loss (IL) of the sensor is simplified as [21]

$$IL = -20 \lg(C) + L_{\text{Au}} \cdot MPA \quad (2)$$

where $MPA = 40\pi \lg(e) \text{Im}(N_{\text{eff}})/\lambda$ is the mode power attenuation of the waveguide. In this work, the normalized transmission is defined as the absorption loss caused by the metal-clad waveguide, excluding the fiber-waveguide end coupling loss.

Fig. 2 Dispersion curves of the waveguide and SPP mode when $w = h = 3 \mu\text{m}$, $d_{\text{Au}} = 50 \text{ nm}$, and $t_b = 500 \text{ nm}$.

The normalized transmission of the device as a function of the wavelength with different external analytes is shown in Fig. 3. There exists a resonance wavelength at 855 nm with an extinction ratio of -72 dB when n_a is 1.33. When n_a increases from 1.33 to 1.36, the maximum absorption wavelength shifts to a longer wavelength. For a fixed operation wavelength of 850 nm, the transmission power increases ΔP , which can be detected by an optical power meter. The SPR sensor described here is designed to operate around $\lambda = 850 \text{ nm}$, which corresponds to a central wavelength of the commercially available laser source. The cost of light sources and detectors or cameras at 850 nm is low that facilitates low-cost and portable sensing applications. And those aqueous solutions with

analytes have a relatively low optical absorption at 850 nm [22, 23]. Varying RIs of analytes, the variation of output power is recorded in real time from the output waveguide. Compared with the spectral interrogation, light intensity interrogation shows advantages of fast response, low cost, and easy integration.

Fig. 3 Normalized transmission as a function of the wavelength when $w = h = 3 \mu\text{m}$, $d_{\text{Au}} = 50 \text{ nm}$, and $t_b = 500 \text{ nm}$.

Figure 4 shows the variation of effective RI of the guided mode with a waveguide width when h is $3.2 \mu\text{m}$. Single mode operation can be achieved within a certain waveguide width from $1 \mu\text{m}$ to $3.5 \mu\text{m}$. Therefore, the width of the waveguide w is set to be $3.2 \mu\text{m}$.

Fig. 4 Effective refractive index of the waveguide mode changes with the core width from $1.0 \mu\text{m}$ to $5.0 \mu\text{m}$.

To realize the best phase matching condition at the wavelength of 850 nm, the thicknesses of the PMMA buffer layer and gold film are optimized. The normalized transmission of the device versus the thickness of the PMMA buffer layer with $h =$

$3.2\ \mu\text{m}$, $w = 3.2\ \mu\text{m}$, $t_{\text{Au}} = 50\ \text{nm}$, and $n_a = 1.33$ is calculated, as shown in Fig. 5(a). The loss firstly increases to a maximum value of $-60\ \text{dB}$ when t_b is around $500\ \text{nm}$ and then decreases, which implies that when t_b is about $500\ \text{nm}$, the coupling efficiency reaches the peak. Since the thickness of gold is directly related to the amount of free electron charge, it has a significant effect on the mode peak attenuation and SPR dip position. Parameters used here are as follows: $w = 3.2\ \mu\text{m}$, $h = 3.2\ \mu\text{m}$, $t_b = 500\ \text{nm}$, and $n_a = 1.33$. As shown in Fig. 5(b), the

loss firstly increases to a maximum value of $-68\ \text{dB}$ when t_{Au} is $51.5\ \text{nm}$ and then decreases. The insets show the mode field distributions of the waveguide at different Au film thicknesses. The mode distributions decay in the waveguide core and most locate in the Au layer when t_{Au} is $51.5\ \text{nm}$, while most of the mode fields distribute in the waveguide core when t_b is $42\ \text{nm}$. Due to a large absorption by the metal, the mode attenuation in the waveguide with the $51.5\ \text{nm}$ thick gold film is greater than those with other thick gold films.

Fig. 5 Normalized transmission changes (a) with the thickness of the PMMA buffer layer and (b) with the thickness of the gold film.

3.1 Effects of thickness of the gold film

In the design of the structure, it is found that the maximal transmission loss happens when the gold film thickness is around $51.5\ \text{nm}$. The influence of the Au thickness on the sensing characteristics is investigated. Figure 6 shows the dependence of the normalized transmission on RI of the analyte for different gold film thicknesses of $46\ \text{nm}$, $48\ \text{nm}$, $50\ \text{nm}$, and $51.5\ \text{nm}$. The structural parameters used here are as follows: $w = h = 3.2\ \mu\text{m}$, $t_b = 500\ \text{nm}$, $\lambda = 850\ \text{nm}$, and $L_{\text{Au}} = 1\ \text{mm}$. It is clear that the transmission increases quasi-linearly with the increment of RI of the analyte and the sensitivity of the sensor changes significantly with the variation of the Au thickness. As the metal becomes thicker from $46\ \text{nm}$ to $51.5\ \text{nm}$, the sensitivity increases about 2.5-fold from $187.81\ \text{dB/RIU}$ to $466.49\ \text{dB/RIU}$. The variation of the thickness of the gold film

significantly affects the dispersion property of the SPP mode and also affects the coupling between the guided mode and SPP mode.

Fig. 6 Dependence of the normalized transmission on RI of the analyte for different gold film thicknesses.

3.2 Effects of the thickness of the PMMA layer

The influence of variation of the PMMA thickness on the sensor is investigated. From

Fig. 5(b), the transmission loss reaches its maximum when t_b is around 500 nm. Similarly, we select 460 nm, 480 nm, and 500 nm thick buffer layers for simulation. Figure 7 depicts the variation of normalized transmission with the increment of RI of the analyte under the condition that $w = h = 3.2 \mu\text{m}$, $t_{\text{Au}} = 50 \text{ nm}$, $\lambda = 850 \text{ nm}$, and $L_{\text{Au}} = 1 \text{ mm}$. As the thickness of the buffer layer increases from 420 nm to 500 nm, the sensitivity increases from 252.9 dB/RIU to 385.19 dB/RIU in the RI range of 1.33 – 1.46 to be measured. The variation of the thickness of the PMMA layer changes the effective index of the two modes, which in turn affects the phase matching condition.

Fig. 7 Dependence of the normalized transmission on RI of the analyte for different thicknesses of the buffer layer.

3.3 Effects of the width and thickness of the waveguide

The normalized transmission changes with the external refractive index for different waveguide widths and different waveguide thicknesses are studied, as shown in Figs. 8 (a) and 8(b). Figure 8(c) shows the sensitivity of the sensor varies with the waveguide width and waveguide thickness. The structural parameters are as follows: $t_b = 500 \text{ nm}$, $\lambda = 850 \text{ nm}$, $t_{\text{Au}} = 50 \text{ nm}$, and $L_{\text{Au}} = 1 \text{ mm}$. The sensitivity increases slightly from 354 dB/RIU to 402 dB/RIU when the waveguide width increases from $2.8 \mu\text{m}$ to $3.4 \mu\text{m}$, because the interaction width between the guided mode and SPP mode, as well as the interaction width between the electric field and

external medium, increases. When h increases from $2.6 \mu\text{m}$ to $3.4 \mu\text{m}$, the sensitivity decreases from

(a)

(b)

(c)

Fig. 8 Dependence of the normalized transmission on RI of the analyte for different (a) waveguide widths, $h = 3.2 \mu\text{m}$, (b) waveguide thicknesses, $w = 3.2 \mu\text{m}$, and (c) the sensitivity of the sensor varies with the waveguide width and waveguide thickness.

516.19 dB/RIU to 340.44 dB/RIU. The thinning of the waveguide results in an increase in the electric field density of the guided layer that strengthens the interaction between the electric field and external medium. Compared with the width of the waveguide, the variation of the waveguide thicknesses has more influence on the sensitivity of the sensor, since the SPP waves are TM polarized.

3.4. Effects of length of the Au sensing area

Figure 9 shows the normalized transmission changes with RI of the analyte for different Au lengths of 0.2 mm, 0.6 mm, and 1 mm. The structural parameters are as follows: $w = h = 3.2 \mu\text{m}$, $t_{\text{Au}} = 50 \text{ nm}$, $\lambda = 850 \text{ nm}$, and $t_b = 500 \text{ nm}$. As can be seen, the sensitivity increases 5-fold from 77.04 dB/RIU to 385.19 dB/RIU as the sensing length increases from 0.2 mm to 1.0 mm, while the transmission loss increases as well. Therefore, there exists a compromise between the sensitivity and the loss when optimizing the length of the Au sensing area.

Fig. 9 Dependence of normalized transmission on RI of analytes for different sensing lengths of 1 mm, 0.6 mm, and 0.2 mm.

4. Results and discussion

According to the above simulations, the parameters are selected as follows: $w = 3.2 \mu\text{m}$, $h = 2.8 \mu\text{m}$, $d_{\text{Au}} = 52 \text{ nm}$, $t_b = 500 \text{ nm}$, and $L_{\text{Au}} = 0.7 \text{ mm}$. The imaginary part of RI of water at 850 nm is around 2.8×10^{-7} [22]. Considering the absorption of light by water, the dependence of normalized

transmission on RI of the analyte is shown in Fig. 10. When RI of the analyte increases from 1.33 to 1.46, the transmission increases quasi-linearly from -75 dB to -10 dB , corresponding to a sensitivity of 491.5 dB/RIU. If the power range of the photodetector is from 500 pW to 5 mW, and the resolution is 100 pW (PM130D, Thorlab, America), the detection limit of the RI sensor is as high as $2.6 \times 10^{-9} \text{ RIU}$, improved by at least two orders of magnitude compared with those of the SPR sensors based on the spectral interrogation [8–12].

Fig. 10 Normalized transmission changes with RI of the analyte.

5. Conclusions

A metal-clad planar waveguide SPR sensor based on EPO polymer materials by using light intensity interrogation at 850 nm is demonstrated. The effects of the gold film thickness, PMMA buffer layer thickness, waveguide layer thickness, waveguide width, and sensing length on sensing performance of the RI sensor have been comprehensively studied. The normalized transmission increases quasi-linearly with the increment of RI of the analyte. The sensitivity changes significantly with the variation of the Au thickness, since the thickness of the gold film directly affects the amount of free electron charge. The sensing sensitivity increases with the decrement of the waveguide thickness. The sensitivity of the sensor is 491.5 dB/RIU in RI range of 1.33 – 1.46

for the Au sensing length of 0.7 mm in the 52-nm-thick Au layer, 500-nm-thick PMMA layer, and $3.2 \times 2.8 \mu\text{m}^2$ waveguide, corresponding to a high RI resolution of 2.6×10^{-9} . A higher sensitivity can be achieved by optimizing the waveguide geometric parameters and materials. The designed hybrid waveguide coupled SPPs-based liquid RI sensor is low-cost, compact, wide-range, and high-precision, and shows a broad application prospect in biochemical and environment sensing fields.

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